

10/588698

Application Data Sheet

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Application Information

Application Type:: Regular
Subject Matter:: Utility
CD-ROM or CD-R?:: None
Computer Readable Form (CRF)?:: No
Title:: METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE AND METHOD OF ETCHING AN INSULATING FILM
Attorney Docket Number:: 039262-0156
Request for Early Publication?:: No
Request for Non-Publication?:: No
Suggested Drawing Figure:: 6
Total Drawing Sheets:: 6
Small Entity?:: Yes
Petition included?:: No
Secrecy Order in Parent Appl.?:: No

Applicant Information

Applicant Authority Type:: Inventor
Primary Citizenship Country:: Japan
Status:: Full Capacity
Given Name:: Tadahiro
Family Name:: OHMI
City of Residence:: Miyagi
Country of Residence:: Japan
Street of mailing address:: 1-17-301, Komegafukuro 2-chome
Aoba-ku, Sendai-shi
Miyagi, 980-0813

Country of mailing address:: Japan

Applicant Authority Type:: Inventor

Primary Citizenship Country:: Japan

Status:: Full Capacity

Given Name:: Tetsuya

Family Name:: GOTO

City of Residence:: Miyagi

Country of Residence:: Japan

Street of mailing address:: 1-11-A203, Yamadahoncho

Taihaku-ku, Sendai-shi

Miyagi, 982-0816

Country of mailing address:: Japan

Correspondence Information

Correspondence Customer Number:: 22428

E-Mail address:: PTOMailWashington@foley.com

Representative Information

Representative Customer Number::	22428	
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Domestic Priority Information

Application::	Continuity Type::	Parent Application::	Parent Filing Date::
This Application	National Stage of	PCT/JP2005/001513	02/02/2005

Foreign Priority Information

Country::	Application number::	Filing Date::	Priority Claimed::
Japan	2004-32607	02/09/2004	Yes

Assignee Information

Assignee Name:: Foundation for Advancement of International Science